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1 Perspective

- Construction of vesicle CdSe nano-semiconductors photocatalysts with improved photocatalytic activity:
- Enhanced photo induced carriers separation efficiency and
- mechanism insight
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ABSTRACT

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Introduction

In the last few years, one of the major purposes of material researchers is to create routes of controlling the structure of materials on specific nanomorphologies. The structure and size of inorganic micro and nanomaterials are well known to

have a significant impact on their widely varying electrical 54 and optical applications. Owing to the special structure, 55 vesicle inorganic micro and nanomaterials as novel materials 56 have paid increasing attentions in various fields of modern 57 science and technology (Nguyen et al., 2014; Liu et al., 2010; 58 Wu and Crudden, 2012; Wu et al., 2013). Their regular vesicle Q4

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structure shows an enhanced surface area and shortens transport distances for charge transport (Lai et al., 2012). So, they have been widely applied in photocatalysis (Dinh et al., 2014; Xue et al., 2013; Ye et al., 2014), solar cells (Dong et al., 2014), adsorption (El-Toni et al., 2014), and separation (Wei et al., 2014; Zhu et al., 2014). In the specific nanomorphologies, vesicle nano-semiconductor has caused widespread concern due to their specific structure and potential applications. Now, a large number of researchers have devoted themselves in exploring versatile methods to prepare vesicle materials (Cao et al., 2010; Fang et al., 2011).

Semiconductor nanocrystals have gained a lot of attention because of the ability to tune their photoresponse by size and surface treatment (Kongkanand et al., 2008). Recently, utilizing semiconductor nanomaterials for obtaining photocatalytic performance has attracted wide attentions in sewage system (Liu et al., 2013; Zhu et al., 2015; Dong et al., 2015).

The tailored structure of vesicle nano-semiconductor will have bright prospects in application in environment and chemistry. Responding to technology needs, a great deal of methods to synthesize versatile vesicle nano-semiconductor has been proposed (Niu et al., 2010). These methods could be roughly divided into two forms: soft template and hard template means. Hard template included silica, polystyrene, latex and resin sphere (Kang et al., 2014; Zhang et al., 2014), post-processing was necessary in hard template method, for example, heat treatment and acid or alkali dissolution, which might impair the morphology and structure of the vesicle nano-semiconductor. While soft template generally touched on vesicle, droplet, and gas bubble to form vesicle structure materials (Sanetuntikul et al., 2014; Wickramaratne and Jaroniec, 2015; Girija et al., 2015). Compared to the hard template method, the synthesis pathway of the soft template method was simplified and the post-processing was needless. Up to now, researchers have made great progress in synthesizing vesicle nano-semiconductor and plenty of proud achievements have been gained. However, it still is a daunting challenge about exploring effective and proportionate ways to prepare vesicle nano-semiconductor materials with appropriate size and good dispersion for promising applications.

CdSe is an n-type semiconductor. Its band gap energy is reported to be in the range from 1.65 to 1.8 eV (Schierhorn et al., 2008), which makes it wide Applications in catalysis, sensor and solar cells. In the meantime, we report a moderate, simple and green liquid phase method to prepare vesicle CdSe nano-semiconductor with controlled diameters base on the soft template (H2 vesicles) method. Vesicle CdSe nano-semiconductor was one-step prepared under open air condition in aqueous solution. The CdSe nanoparticles had a promise of aggregating around the liquid-liquid interface between H2 vesicles and water, which resulted in the formation of vesicle structure. The outstanding features of the present work were as follows: (1) Se powder was used as Se source, which avoided an extra process to perpare the inappropriate Se precursor; (2) all reactions were completed under inert atmosphere protection; (3) the reactions proceeded in aqueous solution, so minimizing the pollution damage to the environment; (4) compared to granular CdSe, vesicle CdSe exhibits more superior photocatalytic performance; (5) the prepared vesicle CdSe nano-semiconductor has

been implemented in remediation of residual antibiotics in 120 water and displayed higher removal efficiency. In addition, 121 the optical properties of the obtained nano-semiconductor 122 were also evaluated.

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1. Experimental section

1.1. Chemicals and materials

Cadmium chloride ($CdCl_2 \cdot 2.5H_2O$), sodium borohydride ($NaBH_4$), 127 3-mercaptopropionic acid ($C_3H_6O_2S$) and cetyltrimethyl ammo- 128 nium chloride ($C_{15}H_{34}ClN$) were purchased from Shanghai 129 Aladdin biochemical Technologies Inc., China. Selenium pow- 130 der (Se) was purchased from Sinopharm Chemical Reagent Co., 131 Ltd., China. All the chemicals were analytical grade and used as 132 received without further purification.

1.2. Preparation of vesicle CdSe nano-semiconductor

In a typical procedure, 0.09134 g CdCl₂·2.5H₂O was added into 135 a 100 mL flask dissolving with 30 mL deionized water. Then, 136 0.65 mmol of 3-mercaptopropionic acid (3-MP) and different 137 qualities of cetyltrimethyl ammonium chloride (CTAC) as a 138 cationic surfactant were added with stirring rate of 450 r/min 139 and stirring time of 5 min. Meanwhile, 0.0592 g Se powders 140 were mixed with 0.3783 g sodium borohydride in a 20 mL 141 round bottom flask and then added with 5 mL deionized 142 water stirring under nitrogen atmosphere until the transpar- 143 ent sol was obtained. When the solution turns clear with 144 white precipitate appeared, the clear liquid was quickly 145 injected into the above solution. Afterward, the solution was 146 continuously stirred for 3 hr in 80°C water bath conditions. 147 The final orange precipitates were collected, washed with 148 distilled water and absolute ethanol, and then dried in 149 vacuum at 40°C for 4 hr.

1.3. Characterizations

XRD patterns were obtained with a D/max-RA X-ray diffrac- Q5 tometer (Rigaku, Japan) equipped with Ni-filtrated Cu K α 153 radiation (40 kV, 200 mA). The 20 scanning angle range was 154 10-80° at a scanning rate of 5°/min. The morphology, 155 microstructure and size of vesicle CdSe nanomaterials were 156 confirmed by high resolution transmission electron micros- 157 copy (HRTEM) (JEM-2100, HR, Electronic Co., Ltd., Japan). UV- 158 vis diffuse reflectance spectra (UV-vis DRS, UV2450, 159 Shimazduo, Japan) of catalyst powder was obtained for the 160 dry-pressed disk samples using Specord 2450 spectrometer 161 (Shimazu, Japan) equipped with the integrated sphere acces- 162 sory for diffuse reflectance spectra, using BaSO₄ as the 163 reflectance sample.). Fourier transform infrared (FT-IR) spec- 164 tra were recorded on a Nicolet Nexus 470 FT-IR (America 165 thermo-electricity Company) with 2 cm⁻¹ resolution in the 166 range 400–4000 cm⁻¹, using KBr pellets. Thermogravimetric Q6 analysis (TGA) curve of catalyst powder was obtained with a 168 comprehensive thermal analyzer (STA499C, Tolerance, 169 Germany). X-ray photoelectron spectroscopy (XPS) data were 170 collected on a PHI5300 analyzer (Perkin Elmer, USA) with 171 aluminum $K\alpha$ radiation.

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